



IPW

Docket No.: X2007.0150
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Hiroshi Saitoh

Application No.: 10/780,723

Confirmation No.: 3284

Filed: February 19, 2004

Art Unit: N/A

For: SEMICONDUCTOR DEVICE AND
MANUFACTURING METHOD
THEREFOR

Examiner: Not Yet Assigned

RESPONSE TO RESTRICTION REQUIREMENT

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the restriction requirement set forth in the Office Action mailed August 11, 2005 (Paper No. 20050804), Applicant hereby provisionally elects Group II, claims 17, 18, 19, 20, 21, 22, 23 and 24 for continued examination without traverse.

Applicants reserve the right to file one or more divisional applications directed to the subject matter of the non-elected claims.

Consideration and allowance of the application is respectfully solicited.

Dated: September 12, 2005

Respectfully submitted,

By Michael J. Scheer

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